

Oral Presentation

[FMC2]Metrology and Manufacturing

Chair: K Kälantär (Global Optical Solutions)

Co-Chair: Toshiaki Nonaka (Merck Performance Materials)

Wed. Nov 27, 2019 3:20 PM - 4:40 PM Room 108 (1F)

4:00 PM - 4:20 PM

[FMC2-3]Researches of Process Reduction for Viewing Angle

Controllable LCD

*Shih-Bin Liu¹, Lujie Wang¹, Jun Jiang¹, Yanbing Qiao¹, Chia-Te Liao¹, Te-Chen Chung¹ (1. InfoVision Optoelectronics (Kunshan) Co., Ltd. (China))

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In this paper, a better condition is found to maintain the thickness of PR for half-tone technology, and some issues of process reduction in B-ITO and M3 layers are solved. These issues of topology for M3 after ashing and last wet etching are still being studied.